

Accepted Manuscript

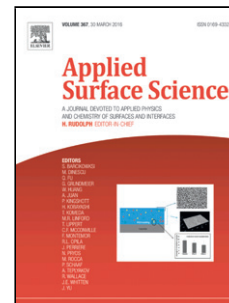
Title: Surface Potentials of (111), (110) and (100) oriented CeO_{2-x} thin films

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PII: S0169-4332(16)30547-5
DOI: <http://dx.doi.org/doi:10.1016/j.apsusc.2016.03.091>
Reference: APSUSC 32857

To appear in: *APSUSC*

Received date: 23-1-2016
Revised date: 9-3-2016
Accepted date: 12-3-2016



Please cite this article as: Hans F. Wardenga, Andreas Klein, Surface Potentials of (111), (110) and (100) oriented CeO_{2-x} thin films, *Applied Surface Science* (2016), <http://dx.doi.org/10.1016/j.apsusc.2016.03.091>

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Surface Potentials of (111), (110) and (100) oriented CeO₂ thin films**Highlights**

- Fermi level positions, work functions and ionization potentials of differently oriented CeO₂ thin films are determined photoelectron spectroscopy
- The state of the surface is varied by different deposition conditions and post-deposition treatments
- The ionization potential varies is more than 2 eV different for most strongly oxidized and reduced surfaces. This 2-3 times as much as observed for other oxide surfaces
- The Fermi level position varies only slightly upon surface oxidation and reduction
- A Ce³⁺ concentration of >10% remains even on the most strongly oxidized surfaces, which exhibit ionization potentials >9 eV

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